



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Yoshihide Senzaki,

Serial No.: **10/686,898**

Filing Date: **October 15, 2003**

For: **Two-Step Atomic Layer Deposition of
Copper Layers**

Examiner: Bret P. Chen

Art Unit No.: 1762

Confirmation
No.: 7540

Date: February 18, 2005

Amendment Response

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313

Sir:

This Amendment Response is in response to the Office Action dated August 18, 2004 received in connection with the above-referenced application. Accompanying this Amendment is a Petition for Extension of Time under 37 CFR 1.136(a) with proper fees, extending the period for response by three months, to February 18, 2005.

Amendments to the Claims are reflected in the listing of claims which begin on page 2 of this paper.

Remarks begin on page 5 of this paper.